

Confirmation No. 6408

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Meunier-Beillard <i>et al.</i>	Examiner:	Khiem Nguyen
Serial No.:	10/550,853	Group Art Unit:	2823
Filed:	September 22, 2005	Docket No.:	NL030357 US1
Title:	METHOD OF EPITAXIAL DEPOSITION OF AN N-DOPED SILICON LAYER		

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**OFFICE ACTION RESPONSE**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Customer No. <b>65913</b>
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Dear Sir:

In response to the non-final Office Action dated October 28, 2008, please reconsider the application in view of the following amendments and remarks.

A complete listing of the Claims and the Remarks/Arguments follow.

**Authorization is provided to charge/credit Deposit Account 50-0996 (NXPS.265PA) any requisite fees/overages to enter this paper.**